

Abstract Submitted  
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**Diffusion of H in In<sub>2</sub>O<sub>3</sub> single crystals**<sup>1</sup> YING QIN, WEIKAI YIN, MIKE STAVOLA, BEALL FOWLER, Lehigh University, LYNN BOATNER, Oak Ridge National Laboratory — An IR absorption line observed at 3306 cm<sup>-1</sup> for In<sub>2</sub>O<sub>3</sub> single crystals annealed in an H<sub>2</sub> ambient has been assigned to an interstitial hydrogen center that acts as a shallow donor [1]. Experiments have been performed to determine the indiffusion depth of interstitial H into In<sub>2</sub>O<sub>3</sub> at temperatures near 400 C. We have also performed annealing experiments in which the outdiffusion of interstitial H is monitored by IR spectroscopy. The goal of these studies is to determine the diffusion constant of interstitial H in In<sub>2</sub>O<sub>3</sub> over a range of temperatures so that the activation energy for diffusion can be determined. [1] W. Yin et al., Phys. Rev. B 91, 075208 (2015).

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